

Listing of Claims

Please cancel claims 47, 48, 57, 58, 61, 64, 68, 69 and 74-87 without prejudice.

The status of the claims of the case are as follows:

Claims 1-39 (canceled)

40. (previously presented) A catalyst having activity under an irradiation of visible light in a wavelength region from about 400 to 600 nm, comprising titanium dioxide having stable oxygen defects and exhibiting NO_x oxidation activity under the irradiation of a visible light at least in the wavelength region of from about 400 to 600 nm; and said titanium dioxide further having a peak area ratio (O1s/Ti2p) of a peak area obtained by X-ray photoelectron spectroscopy assigned to the 1s electrons of oxygen (O1s) participating in the bonds with titanium to a peak area obtained by X-ray photoelectron spectroscopy assigned to the 2p electrons of titanium (Ti2p) of 1.99 or lower.

41. (previously presented) The catalyst according to claim 40, wherein said titanium dioxide component comprises titanium dioxide of an anatase type or a rutile type.

42. (previously presented) The catalyst according to claim 40, wherein the titanium dioxide has a primary particle size of 10 nm or less in diameter.

43. (previously presented) The catalyst according to Claim 40, comprising titanium dioxide that is characterized by an X-ray diffraction (XRD) pattern that is substantially free from patterns other than patterns assigned to anatase type titanium dioxide.

~~44.~~ (previously presented) A catalyst having activity under an irradiation of visible light, said catalyst comprising titanium dioxide having stable oxygen defects and a peak area ratio (O1s/Ti2p) of a peak area obtained by X-ray photoelectron spectroscopy assigned to the 1s electrons of oxygen (O1s) participating in the bonds with titanium to a peak area obtained by X-ray photoelectron spectroscopy assigned to the 2p electrons of titanium (Ti2p) of 1.99 or lower.

~~45.~~ ⁹ (previously presented) The catalyst according to claim ~~44~~, wherein said peak area ratio (O1s/Ti2p) is in a range of from 1.5 to 1.95.

~~46.~~ ¹⁰ (previously presented) The catalyst according to claim ~~44~~, wherein said peak area ratio (O1s/Ti2p) remains substantially constant for time durations of 1 week or longer.

 Claims 47-49 (canceled)

~~30.~~ ¹³ (previously presented) A method for producing a catalyst comprising titanium dioxide having stable oxygen defects and a ratio of a peak area obtained by X-ray photoelectron spectroscopy assigned to the 1s electrons of oxygen participating in the bonds with titanium to a peak area obtained by X-ray photoelectron spectroscopy assigned to the 2p electrons of titanium (O1s/Ti2p) of 1.99 or lower and having activity under an irradiation of a visible light, said method comprising treating the titanium dioxide with hydrogen plasma, characterized by performing said treatment in a state substantially free from an intrusion of air into a treatment system.

31. ¹⁴ (previously presented) The method for producing a catalyst according to claim 50, wherein said treatment is performed in a tightly sealed system and said state substantially free from the intrusion of air into the treatment system is a state in which a vacuum degree inside the tightly sealed system takes at least 10 minutes to make a change of 1 Torr.

32. ¹⁵ (previously presented) The method for producing a catalyst according to claim 50, wherein said oxide semiconductor is selected from the group consisting of titanium dioxide, zirconium oxide, hafnium oxide, strontium titanate, a titanium oxide-zirconium oxide based complex oxide, and a silicon oxide-titanium oxide based complex oxide.

33. ¹⁹ (previously presented) A method for producing a catalyst comprising titanium dioxide having stable oxygen defects and a ratio of a peak area obtained by X-ray photoelectron spectroscopy assigned to the 1s electrons of oxygen participating in the bonds with titanium to a peak area obtained by X-ray photoelectron spectroscopy assigned to the 2p electrons of titanium (O1s/Ti2p) of 1.99 or lower and having activity under an irradiation of a visible light, said method comprising treating the titanium dioxide with a plasma of rare gas, and performing said treatment in a state substantially free from an intrusion of air into a treatment system.

34. ²⁰ (previously presented) The method for producing a catalyst according to claim 33, wherein said state substantially free from the intrusion of air into the treatment system is a state in which a vacuum degree inside a tightly sealed system takes at least 10 minutes to make a change of 1 Torr.

19 35. (previously presented) The method for producing a catalyst according to claim 53, wherein said oxide semiconductor is selected from the group consisting of titanium dioxide, zirconium oxide, hafnium oxide, strontium titanate, a titanium oxide-zirconium oxide based complex oxide, and a silicon oxide-titanium oxide based complex oxide.

20 36. (previously presented) A method for producing a catalyst comprising titanium dioxide having stable oxygen defects and a ratio of a peak area obtained by X-ray photoelectron spectroscopy assigned to the 1s electrons of oxygen participating in the bonds with titanium to a peak area obtained by X-ray photoelectron spectroscopy assigned to the 2p electrons of titanium (O1s/Ti2p) of 1.99 or lower and having activity under an irradiation of visible light, comprising the step of introducing ions of a rare gas on at least a portion of the surface of the titanium dioxide by means of ion implantation.

D1
Claims 57-58 (canceled)

37 39. (previously presented) The method for producing a catalyst according to Claim 50, wherein said oxide semiconductor is an anatase type titanium dioxide.

40 39. (previously presented) The method for producing a catalyst according to Claim 53, wherein said oxide semiconductor is an anatase type titanium dioxide.

Claim 61 (canceled)

41 42. (previously presented) A catalyst produced by the method of Claim 50 and having activity under the irradiation of a visible light.

63. (previously presented) A catalyst produced by the method of Claim 53¹⁹
and having activity under the irradiation of a visible light.

Claim 64 (canceled)

65. (previously presented) The catalyst according to Claim 62¹⁷, wherein said
oxide semiconductor is titanium dioxide, zirconium oxide, hafnium oxide, strontium titanate, a
titanium oxide-zirconium oxide based complex oxide, or a silicon oxide-titanium oxide based
complex oxide.

66. (previously presented) The catalyst according to Claim 68¹³, wherein said
oxide semiconductor is titanium dioxide, zirconium oxide, hafnium oxide, strontium titanate, a
titanium oxide-zirconium oxide based complex oxide, or a silicon oxide-titanium oxide based
complex oxide.

67. (previously presented) The catalyst according to Claim 44¹⁸, wherein said
activity under the irradiation of visible light is an oxidation activity or a reduction activity.

Claims 68-69 (canceled)

68. (previously presented) The catalyst according to Claim 44¹⁸, wherein said
activity under the irradiation of visible light is a decomposition activity for inorganic and organic
substances, or a bactericidal activity.

(previously presented) The catalyst according to claim 40, wherein said catalyst is in a substantially granular, thin-film, or sheet shape.

(previously presented) The catalyst of claim 40, wherein said catalyst material has been provided on the surface of a base material substrate.

(previously presented) The catalyst article according to Claim 12, wherein said base material is an exterior wall of a building, an exterior plane of a roof or a ceiling, an outer plane or an inner plane of a window glass, an interior wall of a room, a floor or a ceiling, a blind, a curtain, a protective wall of highway roads, an inner wall inside a tunnel, an outer plane or a reflective plane of an illuminating light, an interior surface of a vehicle, or a plane of a mirror.

Claims 74-87 (canceled)